

## EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	46127	plasma adj cvd or plasma adj chemical	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/08 10:07
L2	13416	I1 and glass near4 substrate	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/08 10:08
L3	5750	I2 and carbon	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/08 10:09
L4	115	I3 and (silane near4 gas) and (halogen near4 gas)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/08 10:10
L5	0	((plasma adj cvd or plasma adj chemical) and (glass near substrate) and carbon and (silane near4 gas) and (halogen near4 gas)).CLM.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2008/03/08 10:58
L6	1532	(438/787,788, E21.269,E21.274). OCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2008/03/08 11:12

3/ 8/ 08 11:12:27 AM

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